

Light helicity detector based on 2D magnetic semiconductor CrI₃

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Two-dimensional magnetic semiconductors provide a platform for studying physical phenomena at atomically thin limit, and promise magneto-optoelectronic devices application. Here, we report light helicity detectors based on graphene-CrI₃-graphene vdW heterostructures. We investigate the circularly polarized light excited current and reflective magnetic circular dichroism (RMCD) under various magnetic fields in both monolayer and multilayer CrI₃ devices. The devices exhibit clear helicity-selective photoresponse behavior determined by the magnetic state of CrI₃. We also find abnormal negative photocurrents at higher bias in both monolayer and multilayer CrI₃. A possible explanation is proposed for this phenomenon. Our work reveals the interplay between magnetic and optoelectronic properties in CrI₃ and paves the way to developing spin-optoelectronic devices.

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Since the first discovery of intrinsic ferromagnetism in two-dimensional (2D) van der Waals (vdW) crystals of $\text{Cr}_2\text{Ge}_2\text{Te}_6$ and CrI_3 in 2017^{1,2}, 2D magnetic materials have aroused wide research interest. They provide a platform for studying light-matter interactions and magneto-optical/electrical phenomena at the atomically thin limit and also promise magneto-optoelectronic devices application³. Monolayer CrI_3 has ferromagnetic (FM) nature, whereas multilayer CrI_3 has a layered antiferromagnetic (AFM) nature with an easy magnetization axis perpendicular to the layers^{2,4–6}. To date, various studies about CrI_3 were reported, including helical luminescence⁷, tunneling magnetoresistance^{5,6,8} and electrostatic doping⁹, which demonstrated that the optical/electrical properties of CrI_3 are coupled with its magnetic property. To further study 2D magnetic semiconductor materials and advance their application, understanding the interplay between their magnetic and optoelectronic properties and developing magneto-optoelectronic devices are indispensable.

In this work, we fabricate light helicity detectors based on graphene- CrI_3 -graphene vdW heterostructures and study their helical photoresponse properties via magneto-optoelectronic measurements. Devices with two representative thicknesses (monolayer and multilayer) of CrI_3 are investigated. We investigate their circularly polarized light excited current and reflective magnetic circular dichroism (RMCD) under various magnetic fields μ_0H and temperatures. The devices exhibit helicity-selective photoresponse behavior determined by the magnetic state of CrI_3 . Both the helicity-dependent photocurrent and illumination-dependent tunneling current are studied in detail. The calculated photoresponsivity polarization has a clear relation with magnetic field, consistent with the RMCD signals. For the monolayer CrI_3 device, when the applied magnetic field switches the CrI_3 between the up magnetized state ($\mu_0H > 0.1$ T) and the down magnetized state ($\mu_0H < -0.1$ T), the photoresponsivity polarization (ρ) changes between ~ -6 and $+6\%$, and the RMCD signal changes between $\sim +1$ and -1% . The photoresponsivity polarization equals zero, i.e., the helicity-dependent photoresponse phenomenon vanishes, at temperature higher than 40 K, close to the Curie temperature (T_c) of monolayer CrI_3 (45 K)². For the multilayer (14 nm thick) CrI_3 device, ρ value displays multiple plateaus with magnetic field sweeping, and saturates at $\sim \pm 4.5\%$ when $|\mu_0H| > 2.2$ T, corresponding to different spin configurations in CrI_3 enabled by spin-flip transitions at different magnetic fields. Specifically, for both monolayer and multilayer CrI_3 devices, the light-on current decreases with increasing excitation power at a higher bias. Based on detailed discussions, we provide a possible explanation to this phenomenon. Our work reveals the interplay between magnetic and optoelectronic properties in CrI_3 , and paves the way to developing spin-optoelectronic devices.

Results

Device fabrication and characterization. The CrI_3 based light helicity detector was fabricated by mechanically exfoliating and dry transferring few-layer graphene, CrI_3 , and hexagonal boron nitride ($h\text{BN}$) flakes from their bulk crystals to construct graphene- CrI_3 -graphene heterostructure. To avoid degradation⁸, the device was encapsulated by $h\text{BN}$ flakes. The top and bottom graphene layers act as the electrodes. All the procedures were conducted in a glove box within an inert atmosphere (< 0.1 ppm of water and oxygen) (see Methods). Figure 1a, b show the schematic diagram and optical image, respectively, of a monolayer CrI_3 light helicity detector D1. We measured the circularly polarized light excited current and RMCD of the device under various magnetic fields and temperatures. Both the excitation light and magnetic field μ_0H are perpendicular to the 2D layers and parallel to the easy magnetization axis of CrI_3 (see Methods).

Notably, in the experiment, the beam diameter of the excitation light is about $1\ \mu\text{m}$, less than the scale of vertical tunneling junction. For photoresponse and RMCD measurements, the temperature is 2 K and the excitation power is $10\ \mu\text{W}$, unless otherwise specified.

Circularly excited light-on currents. The monolayer CrI_3 device was first fully magnetized at $|\mu_0H| > 0.3$ T. Then its light-on currents (I_{light}) were measured at $\mu_0H = 0$ T under both right circularly polarized light (σ^+) and left one (σ^-) excitations. Their difference ($\Delta I_{\sigma} = I_+ - I_-$) is plotted as a function of applied bias (V) in Fig. 1c, where I_{\pm} are the light-on currents under σ^{\pm} excitations. The ΔI_{σ} - V curves exhibit distinguishable difference between the I_{light} under σ^+ and σ^- excitations, with negative (positive) slope for the up (down) magnetized state of monolayer CrI_3 . These results show that the photocurrent in a fully magnetized CrI_3 is helicity-dependent.

Light Power dependent magneto-optoelectronic response. The excitation power dependent current versus bias relations (I - V curves) of a monolayer CrI_3 with down magnetized state under σ^+ excitation at $\mu_0H = 0$ T (increased from -0.3 T) are shown in Fig. 2a. For identical bias, the I_{light} increases monotonically with the excitation power. We calculate photoresponsivity $R = \frac{I_{\text{ph}}}{P}$, where I_{ph} is the photocurrent defined as $I_{\text{ph}} = I_{\text{light}} - I_{\text{dark}}$, I_{dark} is dark current (i.e., tunneling current in dark), and P is the excitation power. The excitation power dependent R_+ (under σ^+ excitation) and R_- (under σ^- excitation) at $V = 0.2$ V are plotted in Fig. 2b. The clear difference between the R_+ and R_- illustrates again that the photocurrent is helicity-dependent and the device can serve as a light helicity detector¹⁰. The key parameter for a helicity detector is the photoresponsivity polarization defined as $\rho = \frac{R_+ - R_-}{R_+ + R_-}$, where R_{\pm} are the σ^{\pm} photoresponsivities¹¹. Based on the above results, we obtain $\rho \approx -6\%$ (6%) for the up (down) magnetized monolayer CrI_3 at $\mu_0H = 0$ T, which, represented by red (blue) dots in Fig. 2c, is independent of excitation power.

Magnetic order dependence of the helical photocurrents. In order to further investigate the relation between the helical photocurrent and the intrinsic magnetism of the monolayer CrI_3 , we directly measured the photocurrent I_{ph} ($V = 0.15$ V) of D1 under various magnetic fields μ_0H by the lock-in technique. The excitation laser is modulated to switch between σ^+ and σ^- by a quarter wave plate equipped with a motorized rotation stage (see Methods). The circularly polarized photocurrent versus the phase of the quarter-wave plate relations for upstate (red dots) and downstate CrI_3 (blue dots) are opposite (Fig. 2d), with $I_{\text{ph}}(\sigma^+) > I_{\text{ph}}(\sigma^-)$ for the down state CrI_3 , and vice versa. When μ_0H sweeps between ± 0.3 T, the photocurrent behaviors are opposite for σ^+ and σ^- excitation as shown in Fig. 2e. By curve fitting the data as shown in Fig. 2d with a cosine function, we can obtain the corresponding photoresponsivity polarization ρ . When μ_0H sweeps between -0.3 and 0.3 T, ρ changes between 6 and -6% (Fig. 2f), correspondingly, the RMCD signal changes between -1 and $+1\%$ (the inset in Fig. 2f). The monolayer CrI_3 spin-flip transitions occur at ± 0.1 T. While the device exhibits significant magnetic field-dependent helical photocurrent property, the dark tunneling current I_{dark} is almost independent of the magnetic field as shown in Supplementary Fig. 1, because the resistances of the down- or up-magnetized CrI_3 are equal. All the above results demonstrate that the magnetic field-dependent circularly polarized photocurrent can be used to detect the helicity of the incident light.

We also measured the photoresponsivity polarization ρ of the helicity detector D1 under the zero-field-cooling condition (Fig. 3). When the temperature decreases from 80 to 2 K,

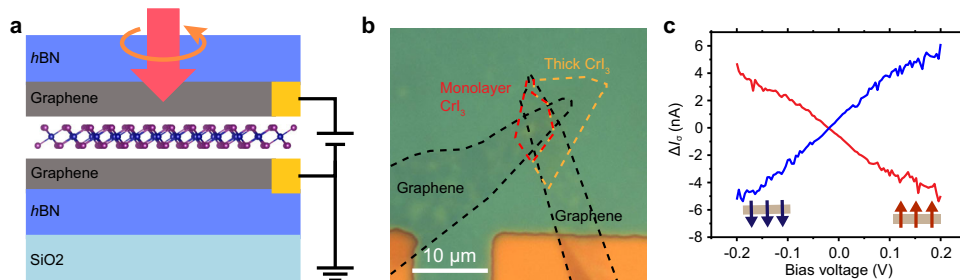


Fig. 1 The monolayer CrI₃ light helicity detector D1. Schematic diagram (a) and optical micrograph (b) of a monolayer CrI₃ (demarkated by the red dashed lines) light helicity detector D1 with few-layer graphene contacts (demarkated by the black dashed lines). The yellow dashed lines demarcate the thick CrI₃, which was not illuminated by the excitation light in the measurements. The device is encapsulated by hBN flakes. **c** The difference of the light-on currents ($\Delta I_{\sigma} = I_{+} - I_{-}$) under σ^{+} and σ^{-} excitations as function of the bias, measured at $\mu_0 H = 0$ T. Before being measured, the monolayer CrI₃ device was fully magnetized at $|\mu_0 H| > 0.3$ T. The red (blue) color denotes up (down) magnetized CrI₃. The ΔI_{σ} -V curve shows negative (positive) slope for up (down) magnetized state of monolayer CrI₃. These results show that the photocurrents in a fully magnetized CrI₃ is helicity-dependent.

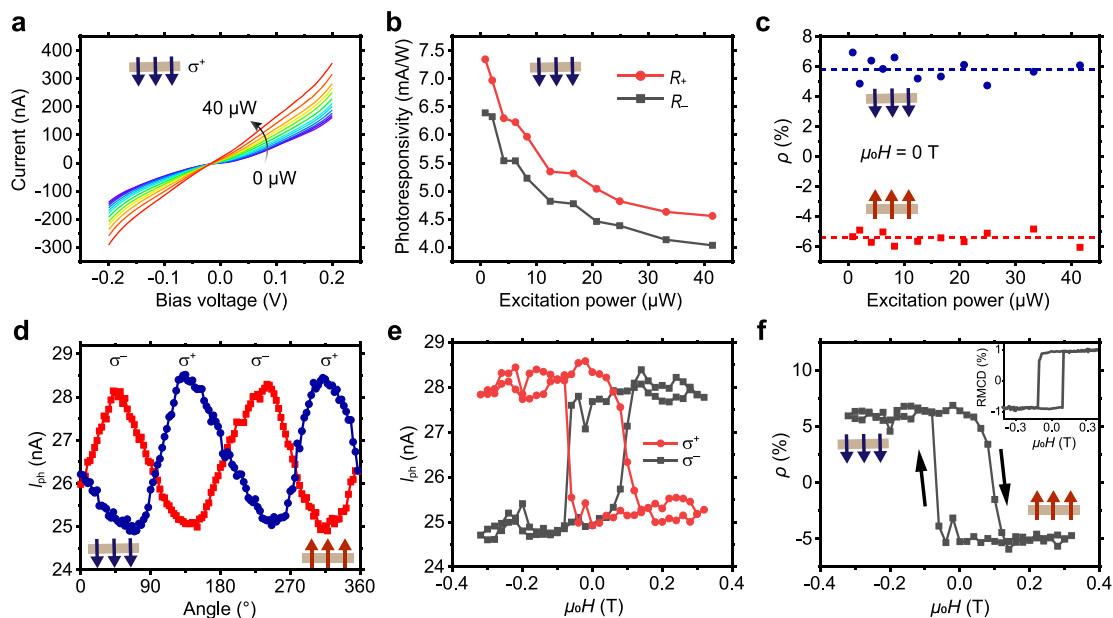


Fig. 2 The magneto-optoelectronic response in the monolayer CrI₃ device D1. **a** I - V curves of the device with a down magnetized state under σ^{+} excitation with various powers (from 0 to 40 μ W) measured at $\mu_0 H = 0$ T (increased from -0.3 T). For identical bias, the light-on current (I_{light}) increases monotonically with the excitation power. **b** Excitation power-dependent photoresponsivities (R_{+} and R_{-}) measured at $V = 0.2$ V under σ^{+} (red) and σ^{-} (black) excitations in the down magnetized state CrI₃. **c** Excitation power dependent photoresponsivity polarization ρ measured at $\mu_0 H = 0$ T. The ρ is independent of excitation power with average values of -6% (red dashed line) for the up state (red dots) and $+6\%$ (blue dashed line) for the down state (blue dots). **d** Photocurrents, measured at $V = 0.15$ V, versus the angle of the quarter-wave plate. The up (down) state CrI₃ exhibits a higher σ^{-} (σ^{+}) photocurrent. **e** Circularly excited photocurrents under various magnetic fields. The red (black) color denotes the σ^{+} (σ^{-}) excitation result. When $\mu_0 H$ sweeps between ± 0.3 T, the photocurrent behaviors are opposite for σ^{+} and σ^{-} excitation. **f** The photoresponsivity polarization ρ values and the reflective magnetic circular dichroism (RMCD) signals (the inset) at various $\mu_0 H$. When $\mu_0 H$ sweeps between -0.3 and $+0.3$ T, ρ changes between 6 and -6% , and RMCD signal changes between -1 and $+1\%$. The CrI₃ spin-flip transitions occur at ± 0.1 T.

ρ increases from 0% to a saturation value of 6% (black dots). By curve fitting the data with $\rho(T) = \rho_0(1 - \frac{T}{T_c})^{\beta}$ (red line), where ρ_0 is the critical amplitude, β is the critical exponent, we obtain $T_c = 40$ K, close to the Curie temperature of monolayer CrI₃ (45 K).

The origin of the helicity-dependent photocurrent can be understood by analyzing the split energy band structure in a fully magnetized CrI₃^{12,13} as shown in Supplementary Fig. 2a. The energy bands for electrons with different spins exhibit different band gaps. The narrower band gap corresponds to majority-spin electrons, and vice versa. Under the 633 nm light excitation, only the majority-spin electrons can be excited and form a few types of excitons^{7,14}. These excitons obey the helicity-selective transition rule (Supplementary

Fig. 2b), determined by the optical selection rules. From the frequency-dependent circularly polarized absorbance of ferromagnetic monolayer CrI₃ at normal incidence¹⁴, we can see that, at the 633 nm (1.96 eV) excitation wavelength, σ^{+} and σ^{-} light absorbances are different, which are dominated by the B⁺ and B⁻ bright exciton absorbances, respectively, leading to the helicity-dependent photocurrent under applied bias. The helicity-dependent absorption is also demonstrated by the RMCD signals (the inset in Fig. 2f), which indicate the difference in reflectivity of the σ^{+} and σ^{-} light (see Methods).

Helical photocurrents in multilayer CrI₃ helicity detector. Figure 4a shows an optical image of a 14 nm thick CrI₃ light

helicity detector D2. The magnetoresistances measured in dark at $V = 0.3$ V under various magnetic fields are shown in Supplementary Fig. 3a. The magnetoresistance is significant with abrupt changes around ± 1 and ± 2 T, consistent with the RMCD result (Fig. 4b). The $I_{\text{dark}}-V$ curves at three representative magnetic field (0, 1.5, and 3 T) are shown in Supplementary Fig. 3b. We can see that, for the applied magnetic fields in our experiment, the tunneling currents in dark are negligible within $V = \pm 0.19$ V. To eliminate the influence of the tunneling current (to be discussed in the next section), herein, the photocurrents are measured at $V = -0.15$ V under various magnetic fields by the lock-in technique. Both the RMCD signal (Fig. 4b) and photoresponsivity polarization ρ (Fig. 4c) show five plateaus when $\mu_0 H$ sweeps between -3.5 and $+3.5$ T, corresponding to five magnetic states enabled by the layered AFM nature of multilayer CrI_3 . The photoresponsivity polarization ρ equals 0 at $\mu_0 H = 0$ T, corresponding to the AFM ground state, and saturates at $\pm 4.5\%$ when $|\mu_0 H| > 2.2$ T, corresponding to the fully spin-polarized states.

The abnormal negative photocurrents at higher bias. The $I-V$ curves of a ~ 10 nm thick CrI_3 light helicity detector D3 are measured at $\mu_0 H = 3$ T under σ^- excitation with various powers (from 0 to 100 μW) (Fig. 5a). The $I-V$ curves are linear within $V = \pm 0.19$ V, but become nonlinear and cross to each other at higher biases (e.g., 0.25 V, the insets in Fig. 5a). Specifically, for

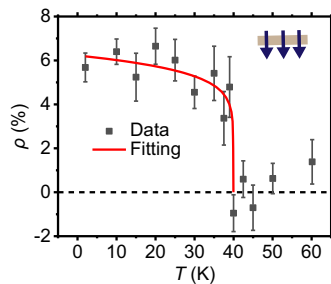


Fig. 3 Temperature-dependent photoresponsivity polarization of the light helicity detector D1 measured at zero magnetic field. As temperature decreases from 80 to 2 K, ρ (black dots) increases from 0% (the dashed line) to a saturated value of 6%, corresponding to the down magnetized state of CrI_3 . The helicities ρ , together with the error bars, are obtained by fitting the relation between the photocurrent and the angle of the quarter-wave plate. By fitting the data with $\rho(T) = \rho_0(1 - T/T_c)^\beta$ (red line), we obtain $T_c = 40$ K.

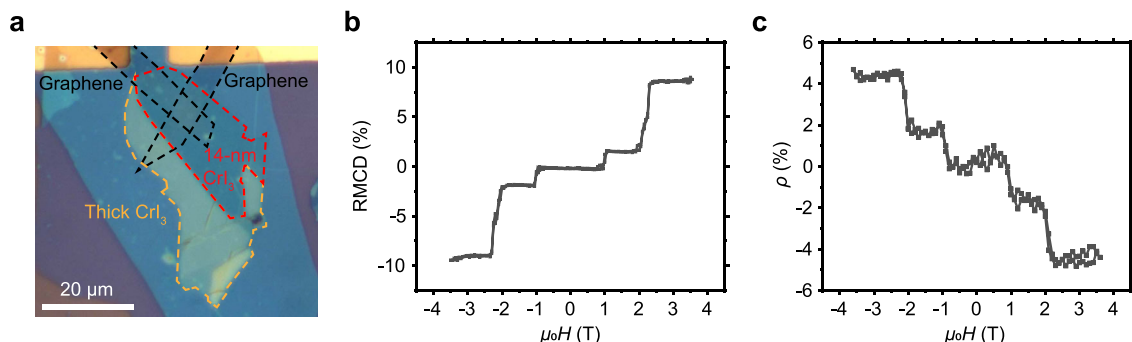


Fig. 4 The multilayer CrI_3 light helicity detector D2. **a** Optical image of the 14 nm thick CrI_3 (demarcated by the red dashed lines) light helicity detector D2 with few-layer graphene contacts (demarcated by the black dashed lines). The yellow dashed lines demarcate the thick CrI_3 , which was not illuminated by the excitation light in the measurements. The device is encapsulated by $h\text{BN}$ flakes. The reflective magnetic circular dichroism (RMCD) signals (**b**) and photoresponsivity polarization ρ (**c**) versus $\mu_0 H$ relations of the device. Both RMCD and ρ show five plateaus when $\mu_0 H$ sweeps between -3.5 and $+3.5$ T, and equal 0 at $\mu_0 H = 0$ T, corresponding to the AFM ground state. RMCD signals and ρ values saturate at ± 10 and $\pm 4.5\%$, respectively, when $|\mu_0 H| > 2.2$ T, corresponding to the fully spin-polarized states.

identical bias within ± 0.19 V, the I_{light} increases monotonically with the excitation power increasing. However, it decreases first and then increases with the excitation power increasing at a higher bias, e.g., $V = 0.25$ V (Supplementary Fig. 4). Such intriguing phenomenon can be reproduced in D2 (Supplementary Fig. 5). We extract the photocurrents I_{ph} by subtracting I_{dark} from I_{light} (Fig. 5a) as shown in Fig. 5b. We can see that, for all the excitation powers, I_{ph} increases linearly with bias within $V = \pm 0.19$ V, but deviates from linear behavior and even decreases at higher bias, resulting in a negative photocurrent. The critical biases of ± 0.19 V coincide with the bias at which I_{dark} becomes significant (see the 0 μW excited $I-V$ curve in Fig. 5a).

In order to explore the abnormal negative photocurrent phenomenon in multilayer CrI_3 devices, we consider that the I_{light} includes the photocurrent I_{ph} and the tunneling current in dark I_{dark} . The I_{ph} includes the photoconductive current I_{pc} and the variation of the tunneling current under light illumination ΔI_{T} . Given a linear relationship between the I_{pc} and applied bias V , we extract the photoconductive current I_{pc} by linear fitting the $I_{\text{ph}}-V$ curve (under 100 μW excitation) within $V = \pm 0.15$ V, and extending the result to the full bias range of ± 0.25 V (red line in Fig. 5c). Next, we obtain the ΔI_{T} (blue line in Fig. 5c) by subtracting I_{pc} (red line) from the photocurrent I_{ph} (black line). We can see that, under light illumination, the tunneling current reduces at a higher bias ($|V| > 0.19$ V), and the reduction magnitude $|\Delta I_{\text{T}}|$ increases monotonically with excitation power (Supplementary Fig. 6). If normalize the $\Delta I_{\text{T}}-V$ and $I_{\text{dark}}-V$ curves by their respective current values at $V = 0.25$ V, we find that the two curves overlap well with each other (Supplementary Fig. 7), indicating that the ΔI_{T} is proportional to the I_{dark} , regardless of the applied bias. These results suggest that the abnormal negative photocurrent phenomenon at higher bias in multilayer CrI_3 devices may result from tunneling current reduction under light illumination.

It is worth noting that the negative photocurrent phenomenon can also be observed in the monolayer CrI_3 device at a higher bias ($|V| > 0.25$ V, Fig. 5d). We plot the dark tunneling current in a $\log(I/V^2)$ vs. $1/V$ diagram^{15,16} to examine the tunneling mechanisms in both monolayer and multilayer CrI_3 . The $\log(I/V^2)-1/V$ curve for monolayer device (Fig. 5e) shows negative (positive) slope at higher (lower) bias region, corresponding to Fowler-Nordheim (FN) tunneling (direct tunneling)¹⁷. Direct tunneling occurs in the lower bias region, i.e., the carriers directly tunnel through a trapezoidal barrier (the right inset in Fig. 5e) without entering into the conduction band of semiconductor¹⁸. FN tunneling occurs in a higher bias region

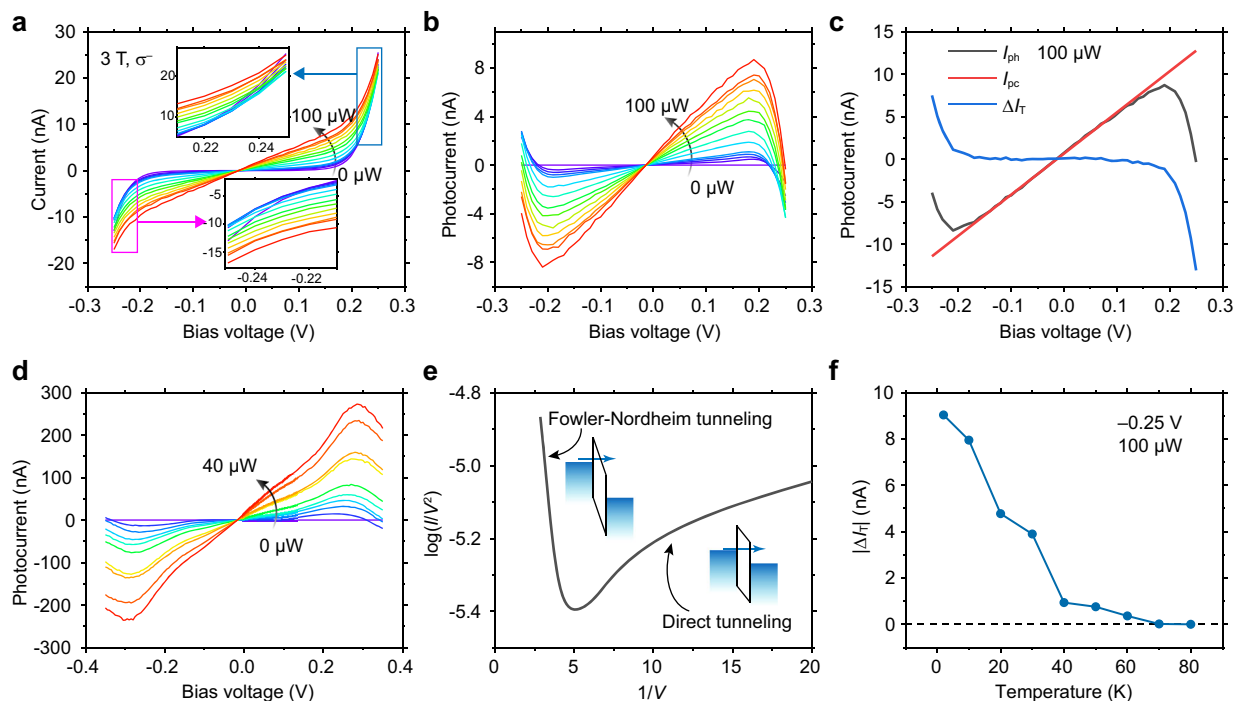


Fig. 5 The abnormal negative photocurrent in the CrI₃ devices. **a** *I*-*V* curves of the ~10 nm thick CrI₃ light helicity detector D3 under σ^- excitation with various powers (from 0 to 100 μ W) at $\mu_0H = 3$ T. The insets: the zoomed-in regions at higher bias. The I_{light} -*V* curves are linear within $V = \pm 0.19$ V, but become nonlinear and cross to each other at higher bias. **b** The photocurrents I_{ph} obtained from (a) by subtracting I_{dark} from I_{light} . For all the excitation powers, the I_{ph} increases linearly with bias within ± 0.19 V, but deviates from linear behavior and even decreases at higher bias, resulting in a negative photocurrent. **c** The I_{ph} -*V* curve under 100 μ W excitation (black line), the I_{pc} -*V* curve extracted by linear fitting the I_{ph} -*V* curve within $V = \pm 0.15$ V, and extending the result to the full bias range of ± 0.25 V (red line), and the ΔI_T -*V* curve (blue line) obtained by subtracting I_{pc} from I_{ph} . Under light illumination, the tunneling current decreases for bias voltages $|V| > 0.19$ V. **d** The I_{ph} -*V* curves in the monolayer CrI₃ device D1 under various excitation powers at $\mu_0H = 0$ T. The negative photocurrent phenomenon occurs at bias higher than 0.25 V. **e** The dark tunneling currents in the monolayer CrI₃ device D1 are plotted in the $\log(I/V^2)$ - $1/V$ diagram. The negative (positive) slope of the curve at high (low) bias region indicates the Fowler-Nordheim tunneling (direct tunneling) mechanism. The two insets: the energy band diagrams of the two tunneling mechanism, the left for the Fowler-Nordheim tunneling and the right for the direct tunneling. **f** The temperature-dependent $|\Delta I_T|$ in D3 measured at $V = -0.25$ V under 100 μ W light excitation. With the temperature increasing, $|\Delta I_T|$ decreases monotonously until zero (the dashed line) at a temperature higher than 60 K.

(>0.25 V for monolayer CrI₃ case), wherein the energy band bends more and the electrons tunnel into the conduction band of the semiconductor (the left inset in Fig. 5e)^{6,8}. The $\log(I/V^2)$ - $1/V$ curve for the ~10-nm CrI₃ device D3 is shown in Supplementary Fig. 8, where the FN tunneling occurs at $V > 0.19$ V. These results indicate that there exists a relationship between the abnormal photocurrent and the tunneling current with FN tunneling mechanism.

We further perform the temperature-dependent measurement in the ~10 nm thick CrI₃ device D3. As temperature increases, the $|\Delta I_T|$ (measured at $V = -0.25$ V) exhibits a monotonous decrease until zero at a temperature higher than the Curie temperature of CrI₃ ($T_c = 61$ K⁴). This result indicates that the negative photocurrent phenomenon weakens as temperature increases, and vanishes at temperature higher than 60 K. The temperature dependence of the dark tunneling current I_{dark} for the 10-nm CrI₃ device is shown in Supplementary Fig. 9a. As the temperature increases from 2 K, the I_{dark} first decreases and then increases. The turning point is 60 K. Similar result was reported previously for CrI₃ tunneling device⁸. The I_{ph} -*V* relations at various temperatures are shown in Supplementary Fig. 9b. At lower temperature, the I_{ph} -*V* curves are nonlinear due to the negative photocurrent. As temperature increases, the I_{ph} -*V* curves become linear, corresponding to the weakening negative photocurrent phenomenon.

One possible origin for the abnormal negative photocurrent phenomenon is the light-induced defects in CrI₃¹⁹. The defects

may trap the electrons which tunnel into the conduction band of CrI₃ through FN tunneling, resulting in reduced conductivity. At higher temperatures ($k_B T >$ activation energy of the trapped electron), the trapped electrons would release and contribute again to conductivity. Therefore, the absolute value of ΔI_T decreases with increasing temperature as shown in Fig. 5f. Nevertheless, to fully verify this, further study of dynamic process of the interaction between photons and electrons is needed.

Discussion

In conclusion, we fabricated light helicity detectors based on graphene-CrI₃-graphene vdW heterostructures and measured their circularly polarized light excited current and RMCD under various magnetic fields. The helicity-dependent photocurrent has a clear relation with a magnetic field, consistent with the RMCD result. For the monolayer CrI₃ device D1, the photoresponsivity polarization switches between $\pm 6\%$ as the magnetic field sweeps between ± 0.3 T. The helicity-dependent photoresponse phenomenon vanishes at temperature higher than 40 K, close to the Curie temperature (T_c) of monolayer CrI₃ (45 K). For the multilayer CrI₃ device, the photoresponsivity polarization performs AFM properties that saturates at $\pm 4.5\%$ when $|\mu_0H| > 2.2$ T, and equals 0 at $\mu_0H = 0$ T. Moreover, we find abnormal negative photocurrent phenomenon at higher bias in both monolayer and multilayer CrI₃. We try to unveil the origin of this phenomenon by investigating the tunneling current mechanism in CrI₃, together with the temperature dependent measurement. Our work

reveals the interplay between magnetic and optoelectronic properties in CrI₃ and paves the way to developing spin-optoelectronic devices.

Methods

Device fabrication. First, few-layer graphene, CrI₃, and hBN (10–30 nm) flakes were exfoliated onto polydimethylsiloxane (PDMS) substrates in an argon gas-filled glove box with <0.1 ppm concentration of oxygen and water. Then, the hBN encapsulated graphene-CrI₃-graphene heterostructure was assembled layer-by-layer on a Si/SiO₂ substrate in the same glove box with the dry transferring method using the PDMS substrate as stamp under the help of a microscope attached with a micro-manipulator. The two graphene electrodes were contacted to the pre-prepared Cr/Au (5/25 nm) electrodes for measuring purpose. The thicknesses of the flakes were estimated by optical contrast and confirmed by atomic force microscopy after device measurements.

RMCD and magneto-optoelectronic measurements. Both RMCD and magneto-optoelectronic measurements were performed in a dry cryostat (attoDRY2100, base temperature of 1.7 K) equipped with a 9 T superconducting magnet and a home tailored microscopic setup in back-scattering geometry. The RMCD is defined as $(R_{\sigma+} - R_{\sigma-}) / (R_{\sigma+} + R_{\sigma-})$, where $R_{\sigma\pm}$ are the intensities of the σ_{\pm} reflected light. For RMCD measurement, the temperature was 2 K, and the device was illuminated by a 633 nm He-Ne laser with a power of 10 μ W. The laser was modulated by a chopper and a photoelastic modulator (PEM100), and was focused on the device with a beam diameter \sim 1 μ m by a low-temperature apochromatic objective (LT-APO/VISIR/0.82). The collected light from the sample via the same objective was sent to a photomultiplier tube (PMT1001) equipped with a lock-in amplifier (HF2L). For magneto-optoelectronic measurement, circularly polarized light was realized by modulating the 633 nm He-Ne laser with a polarizer and a quarter wave plate equipped with a motorized rotation stage. A chopper was employed to switch the light between on and off states with a frequency of 73 Hz. The photocurrent was measured directly by the lock-in amplifier. The I - V curves were measured with a Keithley 2636B source/measure unit. The temperature was 2 K and the excitation power was 10 μ W, unless otherwise specified.

Data availability

All relevant data are available from the corresponding author on request.

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Author contributions

L.D. and X.C. conceived the project. X.C. fabricated the devices in collaboration with Z.C. and M.L.; X.C. conducted the measurements; X.C. and L.D. performed data analysis. C.W. and W.J. helped with the theoretical analysis and calculation. P.G. helped with the magnetoresistance measurements. S.Y. grew the CrI₃ crystals. Y.L. prepared the metal electrodes. T.T. and K.W. provided the hBN crystals. L.D. supervised this research. X.C. and L.D. wrote the manuscript. All authors contributed to discussions.

Competing interests

The authors declare no competing interests.

Additional information

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